ASMMC.9CP1DV1C1 PATENT

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

**Applicant** 

Sherman

Appl. No.

10/683,727

Filed

October 10, 2003

For

SEQUENTIAL CHEMICAL

**VAPOR DEPOSITION** 

Examiner

Kelly M. Stouffer

Group Art Unit

1762

## **AMENDMENT AND RESPONSE TO OFFICE ACTION**

## Mail Stop Amendment

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

## Dear Sir:

The present paper is submitted in response to the Office Action mailed on October 31, 2006. Applicant respectfully requests consideration of the subsequent remarks.

Amendments to the Specification begin on page 2 of this paper.

Amendments to the Claims are reflected in the listing of claims which begins on page 3 of this paper.

Remarks/Arguments begin on page 4 of this paper.